Application No. 10/091,373

Amendment dated September 24, 2004

Reply to Office Action of March 24, 2004

LISTING OF THE CLAIMS

1. (Currently amended) A copolymer prepared by copolymerization of: a first monomer having the structure of formula (1)

(I) $R^{23} \longrightarrow R^1$

wherein

R1 is II, F, CN, CH3, or C1-6 fluoroalkyl,

R^{2a} and R^{2b} are independently H or F, and

 R^3 is CN or COOR, wherein R is selected from the group consisting of H, C_{1-12} alkyl and C_{1-12} fluoroalkyl, or is selected so as to render R^3 acid-cleavable; and

____a second monomer having the structure of formula (II)

(II) $\begin{array}{c}
R^6 \\
R^7
\end{array}$

wherein

R4 is H, C1-12 alkyl, C3-15 alicyclic, or fluorinated C3-15 alicyclic,

 R^5 is C_{1-12} alkyl, C_{1-12} alkyl substituted with 1-12 fluorine atoms and 0-2 hydroxyl groups, or C_{3-15} alicyclic, or R^4 and R^5 together form a five-, six-, or seven-membered ring,

 R^6 is H, $C_{1\text{-}12}$ alkyl, or $C_{1\text{-}12}$ fluoroalkyl, or R^4 and R^6 together form a five-, six-, or seven-membered ring, and

 R^7 is H, C_{1-12} alkyl, or C_{1-12} fluoroalkyl, or R^7 and R^5 together represent -X-(CR^8R^9)_n-, in which case R^4 and R^6 are H, X is O or CH₂, n is 1 or 2, R^8 and R^9 are H, C_{1-12} alkyl, or C_{1-12} fluoroalkyl, or together form an oxo moiety (=O), with the proviso that when R^8 and R^9 together form =O, n is 1,

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wherein any of R¹, R³, R⁴, R⁵, R⁶, and R⁷ may be further substituted with an inert, nonhydrogen substituent, and further wherein at least one of the first monomer and the second monomer contains one or more fluorine atoms.

- 2. (Previously amended) The copolymer of Claim 29, wherein R¹ is CF₃.
- 3. (Original) The copolymer of Claim 2, wherein R³ is COOR.
- 4. (Original) The copolymer of Claim 2, wherein R³ is CN.
- 5. (Original) The copolymer of Claim 1, wherein R¹ and R² are F and R³ is COOR.
- 6. (Original) The copolymer of Claim 1, wherein R¹ is CN and R² is H.
- 7. (Original) The copolymer of Claim 3, wherein R is C_{1-12} alkyl.
- 8. (Original) The copolymer of Claim 5, wherein R is C_{1-12} alkyl.
- Original) The copolymer of Claim 3, wherein R is selected to render R³ acidcleavable.
- 10. (Original) The copolymer of Claim 5, wherein R is selected to render R³ acidcleavable.
 - 11. (Original) The copolymer of Claim 10, wherein R is a tertiary alkyl substituent.
 - 12. (Original) The copolymer of Claim 11, wherein R is t-butyl.
- 13. (Original) The copolymer of Claim 11, wherein R is a C_5 - C_{12} cyclic or alicyclic substituent with a tertiary attachment point.

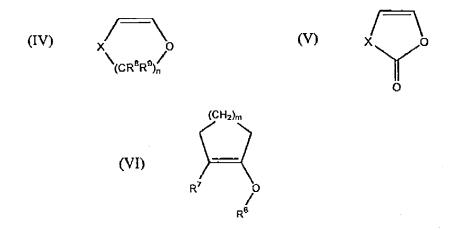
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- 14. (Previously amended) The copolymer of Claim 13, wherein R is selected from the group consisting of 2-methyl-2-adamantyl, 2-methyl-2-isobornyl, 2-methyl-2-tetracyclododecenyl, 2-methyl-2-dihydrodicyclopentadicnyl-cyclohexyl,1-methylcyclopentyl, and 1-methylcyclohexyl.
- 15. (Previously amended) The copolymer of Claim 1, wherein the second monomer has the structure of formula (III)

wherein:

R⁴ is H, C₁₋₁₂ alkyl, C₃₋₁₅ alicyclic, or fluorinated C₃₋₁₅ alicyclic; and R⁵ is C₁₋₁₂ alkyl, C₁₋₁₂ alkyl substituted with 1-12 fluorine atoms and 0-2 hydroxyl groups, or C₃₋₁₅ alicyclic.

16. (Previously amended) The copolymer of Claim 1, wherein the second monomer has a structure selected from the group consisting of (IV), (V), and (VI)



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wherein:

 R^6 is II, C_{1-12} alkyl, or C_{1-12} fluoroalkyl; R^7 is II, C_{1-12} alkyl, or C_{1-12} fluoroalkyl; X is O or CH₂; m is an integer between 1 and 3; and R^8 and R^9 are H, C_{1-12} alkyl, or C_{1-12} fluoroalkyl.

- 17. (Original) The copolymer of Claim 1, wherein the copolymer is substantially transparent to radiation having a wavelength of less than about 250 nm.
- 18. (Original) The copolymer of Claim 17, wherein the copolymer is substantially transparent to radiation having a wavelength of less than about 193 nm.
- 19. (Original) The copolymer of Claim 18, wherein the copolymer is substantially transparent to radiation having a wavelength of 157 nm.
- 20. (Original) The copolymer of Claim 1, further comprising at least one additional monomer having a structure that is different that the first and second monomers.
- 21. (Original) A lithographic photoresist composition comprising the copolymer of Claim 1 and a radiation-sensitive acid generator.
- 22. (Original) The lithographic photoresist composition of Claim 18, further comprising a second polymer.
- 23. (Previously amended) A process for generating a resist image on a substrate, comprising the steps of:
- (a) coating a substrate with a film of a photoresist comprised of a radiation-sensitive acid generator and a copolymer synthesized from a first monomer having the structure of formula (I)

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wherein

R¹ is H, F, CN, CH₃, or C₁₋₆ fluoroalkyl,

R^{2a} and R^{2b} are independently H or F, and

R³ is CN or COOR, wherein R is selected from the group consisting of II, C₁₋₁₂ alkyl and C₁₋₁₂ fluoroalkyl, or is selected so as to render R³ acid-cleavable, with the proviso that when R³ is CN, then R¹ is CF₃ and R^{2a} and R^{2b} are H; and a second monomer having the structure of formula (II)

(II)
$$\mathbb{R}^{7}$$

wherein

R⁴ is H, C₁₋₁₂ alkyl, C₃₋₁₅ alicyclic or fluorinated C₃₋₁₅ alicyclic,

 R^5 is C_{1-12} alkyl, C_{1-12} alkyl substituted with 1-12 fluorine atoms and 0-2 hydroxyl groups, or C_{3-15} alicyclic, or R^4 and R^5 together form a five-, six-, or seven-membered ring,

 R^6 is H, C_{1-12} alkyl, or C_{1-12} fluoroalkyl, or R^4 and R^6 together form a five-, six-, or seven-membered ring,

 R^7 is H, C_{1-12} alkyl, or C_{1-12} fluoroalkyl, or R^7 and R^5 together represent -X-(CR^8R^9)_n-, in which case R^4 and R^6 are H, X is O or CH₂, n is 1 or 2, R^8 and R^9 are H, C_{1-12} alkyl, or C_{1-12} fluoroalkyl, or together form an oxo moiety (=O), with the proviso that when R^8 and R^9 together form =O, n is 1,

wherein any of R¹, R³, R⁴, R⁵, R⁶, and R⁷ may be further substituted with an inert nonhydrogen substituent;

- (b) exposing the film selectively to a predetermined pattern of radiation so as to form a latent, patterned image in the film; and
 - (e) developing the latent image with a developer.

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24. (Previously amended) In a lithographic photoresist composition comprised of a polymer transparent to deep ultraviolet radiation and a radiation-sensitive acid generator, the improvement comprising employing as the polymer a copolymer synthesized from a first monomer having the structure of formula (I)

wherein

R¹ is H, F, CN, CH₃, or C₁₋₆ fluoroalkyl, R^{2a} and R^{2b} are independently H or F, and

R³ is CN or COOR, wherein R is selected from the group consisting of II, C₁₋₁₂ alkyl and C₁₋₁₂ fluoroalkyl, or is selected so as to render R³ acid-cleavable, with the proviso that when R³ is CN, then R¹ is CF₃ and R² is H, and a second monomer having the structure of formula (II)

(II)
$$\mathbb{R}^{6} \longrightarrow \mathbb{R}^{4}$$

wherein

R4 is II, C1-12 alkyl, C3-15 alicyclic, or fluorinated C3-15 alicyclic,

 R^5 is C_{1-12} alkyl, C_{1-12} alkyl substituted with 1-12 fluorine atoms and 0-2 hydroxyl groups, or C_{3-15} alicyclic, or R^4 and R^5 together form a five-, six-, or seven-membered ring,

 R^6 is H, C_{1-12} alkyl, or C_{1-12} fluoroalkyl, or R^4 and R^6 together form a five-, six-, or seven-membered ring;

 R^7 is II, C_{1-12} alkyl, or C_{1-12} fluoroalkyl, or R^7 and R^5 together represent -X-(CR^8R^9)_n-, in which case R^4 and R^6 are H, X is O or CH_2 , n is 1 or 2, R^8 and R^9 are H,

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 C_{1-12} alkyl, or C_{1-12} fluoroalkyl, or together form an oxo molety (=0), with the proviso that when R^8 and R^9 together form =0, n is 1,

wherein any of R¹, R³, R⁴, R⁵, R⁶, and R⁷ may be further substituted with an inert nonhydrogen substituent.

- 25. (Original) The lithographic photoresist composition of Claim 24, wherein the photoresist composition is a positive resist and further comprises a photoacid-cleavable monomeric or polymeric dissolution inhibitor.
- 26. (Original) The lithographic photoresist composition of Claim 24, wherein the photoresist composition is a negative resist and further comprises a crosslinking agent.
- 27. (Original) The lithographic photoresist composition of Claim 26, wherein the crosslinking agent is a glycoluril compound.
- 28. (Original) The lithographic photoresist composition of Claim 27, wherein the glycoluril compound is selected from the group consisting of tetramethoxymethyl glycoluril, methylpropyltetramethoxymethyl glycoluril, methylphenyltetramethoxymethyl glycoluril, and mixtures thereof.
- 29. (Previously added) The copolymer of claim 1, wherein R¹ is H, F, CN, CH₃, CF₃, CF₂H, or CFH₂.
- 30. (Previously added) The copolymer of claim 29, wherein at least one of R^1 , R^3 , R^4 , R^5 , R^6 , or R^7 is further substituted with an inert nonhydrogen substituent.
- 31. (Previously added) The copolymer of claim 30, wherein the inert nonhydrogen substituent is selected from the group consisting of F, C_{1-12} alkyl, C_{1-12} alkoxy, C_{1-12} alkenyl, C_{1-12} alkenyloxy, C_{1-12} fluoroalkyl, C_{1-12} fluoroalkyl, and C_{1-12} fluoroalkenyl.

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